

Design and preparation of low absorbing antireflection coatings using chemical spray pyrolysis

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Abstract

Transmission of laser optical elements has been increased when Indium tin oxide (ITO) thin film of relatively high index with different content of Sn was used to prepare ultra thin antireflection coating (ARC's) utilizing simple, low cost non-vacuum chemical spray pyrolysis technique. Two plans were established to achieve the goal: theoretical transmission analysis of ITO film on glass was first carried on with the aid of TFCAL software taking into account the effect of absorption, dispersion and ITO thickness variation on transmission profile. This step provides a clear vision and preliminary thickness range of ITO films before sample preparation with spray pyrolysis method. Results show that XRD spectra reveals that all the films were cubic polycrystalline. Both scanning electron microscope and atomic force microscope indicate that the surface roughness increase with Sn content. Thus, durable and adhesive antireflection ITO ultrathin film, of good transmittance profile was achieved at Nd-YAG laser line of 1.064 μm wavelength when preparation conditions were optimum control.

Keywords: Low absorbing antireflection coating, transfer matrix theory, ITO material.

1. Introduction

Indium tin oxide (ITO) thin films have attracted intensive interest during the last four decades^[1-11]. Their unique properties such as, high transparency in the visible range, high conductivity combined with low resistivity and high reflectivity, wide band gap of around 3.7 eV^[12-15] made them useful in industry. Owing to these properties indium tin oxide was used in many applications, especially light emitting diode^[16,7], gas sensors^[18,19], electrodes^[20,21], biosensor^[22], sound source devices^[23], resistive touch panel^[24] and solar cells^[25-28].

Antireflection coatings (ARC's) are among the most investigated class of optical coatings. It is a type of optical coating or filters applied to the surface of lenses and other optical elements to reduce reflection. They are classified into a single layer of quarter-wave optical thickness ($nd=\lambda_0/4$) having virtual zero reflectance at center (design) wavelength λ_0 to multilayer having low reflectance over a broadband of wavelength^[29-32]. Although the absorption of ITO was very low, mismatch exists between the refractive index of ITO ($n\sim 2.0$)^[33-35] and air ($n=1.0$). This causes a significant reflection, particularly in the visible range, and consequently reduces visible transmittance. In this work, ITO film with low absorption characteristic was designed and prepared as antireflection coating using TFCal.^[36] and spray pyrolysis solution to enhance near infrared transmittance of ITO/glass.

2. Experimental Details

Indium tin oxide was deposited on an ultrasonically cleaned glass substrate using a proper, low cost, chemical spray pyrolysis technique. A precursor solution of deionized water with 0.05 M InCl_3 supplied from (Thomas Baker Chemicals India) as a source of In, while 0.05 M of $\text{SnCl}_4 \cdot 5\text{H}_2\text{O}$ supplied from (Chemical Point Germany) dissolved in deionized water was used as a source of Sn doping material of volumetric concentration 5% and 10%. The prepared solutions were appropriately mixed to obtain the starting solution and was sprayed immediately to preclude any potential chemical change with time. Many trials have been adopted in order to obtain homogeneous thin films, pinhole free and well adherent to the substrate. These optimization conditions were arrived at the following: the substrate temperature was electronically controlled by chromel alumel thermocouple and kept at 450 °C during the deposition process. The distance between substrate and nozzle was 28 cm, the carrier gas was nitrogen and was fixed at 3.5 Bar. The solution flow rate preserved at 5 ml/min, spraying time was 10 s followed by 2 min waiting to avert immoderate cooling.

The crystallinity of the films was examined by X-ray diffraction (XRD), while surface topography was estimated from atomic force microscopy (AFM) images. Surface morphology on the other hand was obtained by scanning electron microscope (SEM). The optical spectra were recorded using (uv probe 1240 Shimadzu Japan) in the wavelength range (330-1100) nm.

2. Transfer Matrix Theory

We describe briefly the transfer matrix method ^[29-32] used to evaluate the reflectance and transmittance in addition to absorption and dispersion of layer film on a known substrate. For normal and near normal incidence the relationship between the magnitude of the electric E and magnetic H vectors in the medium of incidence [interface a in (Fig.(1))] to that in the substrate of index n_s [interface b] can be expressed as follows:

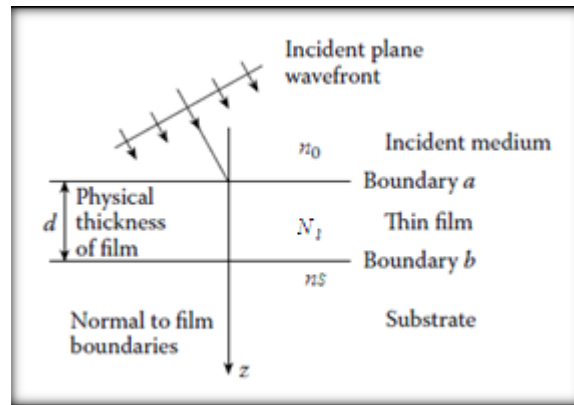


Fig.(1) Plane waves incident on thin- film[27]

$$\begin{bmatrix} E_a \\ H_a \end{bmatrix} = \begin{bmatrix} \cos\delta & i\sin\delta/N_1 \\ iN_1\sin\delta & \cos\delta \end{bmatrix} \begin{bmatrix} E_b \\ H_b \end{bmatrix} \quad \dots\dots(1)$$

Where $N_1 = n_1 - ik_1$ is the complex refractive index of the layer of thickness d_1 . n_1 and k_1 are the refractive index and extinction coefficient. $\delta = 2\pi N_1 d/\lambda$ is the phase thickness of the layer.

Adopting the "Input Optical Admittance" concept $Y = \frac{H_a}{E_a}$, the reflectance R and transmittance T of layer are :

Where $Re(N)$ represent the real part of N . For absorbing- free material ,the necessary condition of AR coating is :

$$n_1 = \sqrt{n_0 n_s} \quad \text{and} \quad n_1 d = \lambda_0/4 \quad \dots\dots(4)$$

3. Results and Discussion

3.1 Structural properties

Figure (2) depicts the XRD patterns of the as deposited indium tin oxide with 5% and 10% Sn concentrations. These films show a major (222) and (400) planes, with three minor peaks correspond to (211), (440) and (622) planes, indicating that the structure is cubic polycrystalline, which agrees with JCPDS card no. 06.0416. No trace for Sn or any of its oxide was observed in these patterns. It can be concluded that the tin atoms were likely being substitutionally doped into indium matrix. The prevalent orientation peak was changed from (400) to (222) as the Sn concentration increase. This might be due to the increase in the amount of incorporating oxygen^[35]. The full width at half maximum decrease as the Sn concentration increase suggested that the grain size also increased.

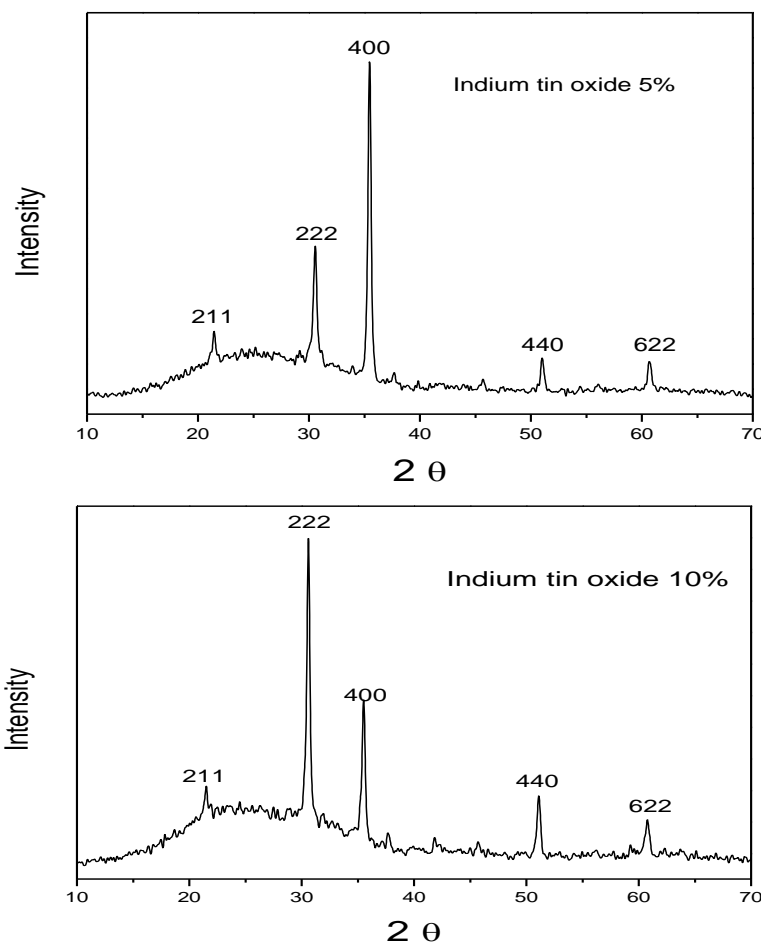


Fig. 2 XRD patterns for indium tin oxide a) 5% Sn concentration b) 10% Sn concentration.

Fig. 3 shows AFM images of ITO with different Sn 5% and 10% content. It was noticed that the value of RMS roughness and the average grain size for Sn 5% which were equal to 2.14 nm and 92.39 nm respectively, increased to 3.11 nm and 101.74 nm as the Sn content increase to 10%.

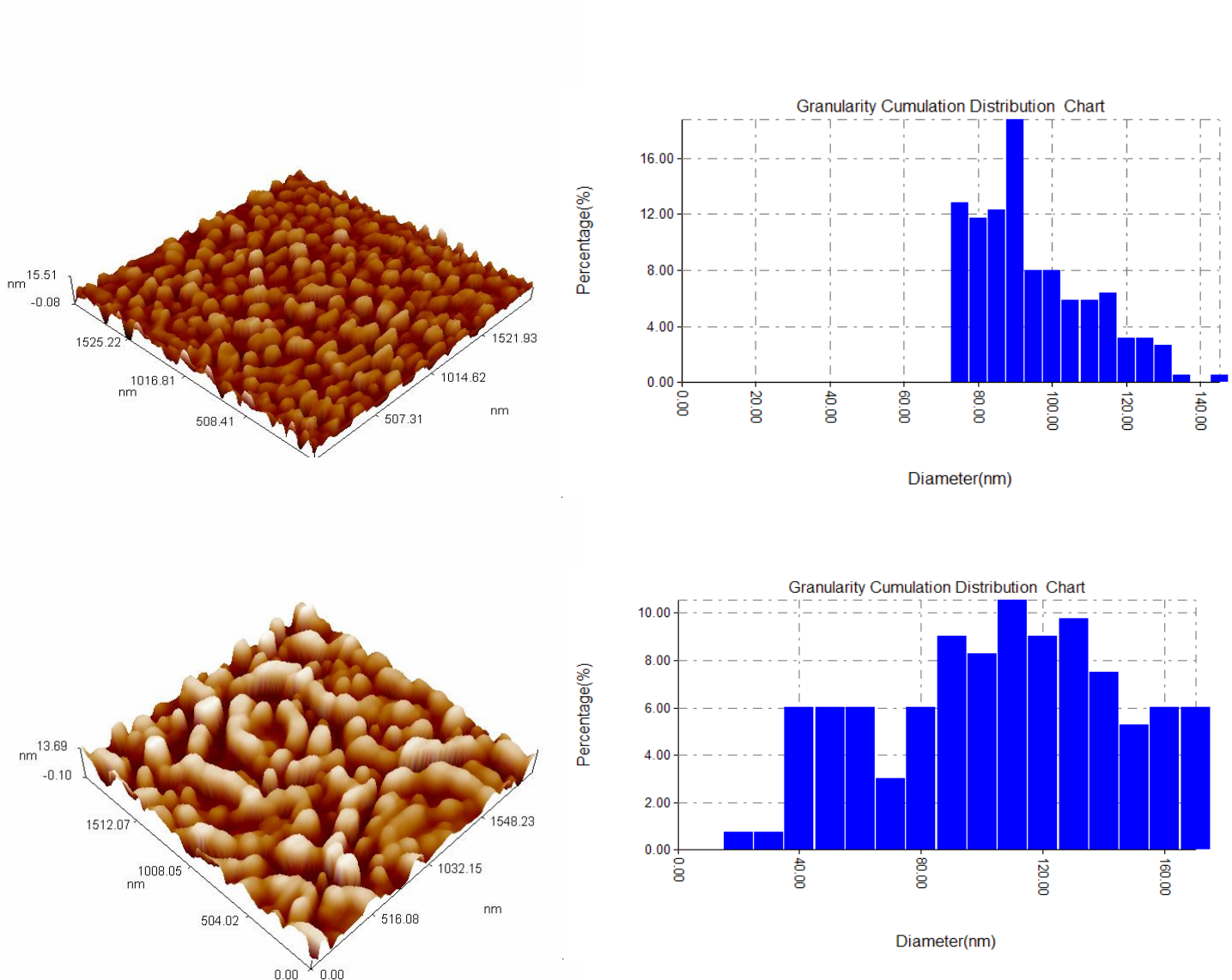


Fig. 3 AFM images of indium tin oxide a) 5% Sn concentration b) 10% Sn concentration.

SEM images show a fine and uniform distribution of grains as shown in Fig. 4 . There was a worthy change in these images because of tin concentration . It was observed that porosity decrease with the increase of grain size and Sn content.

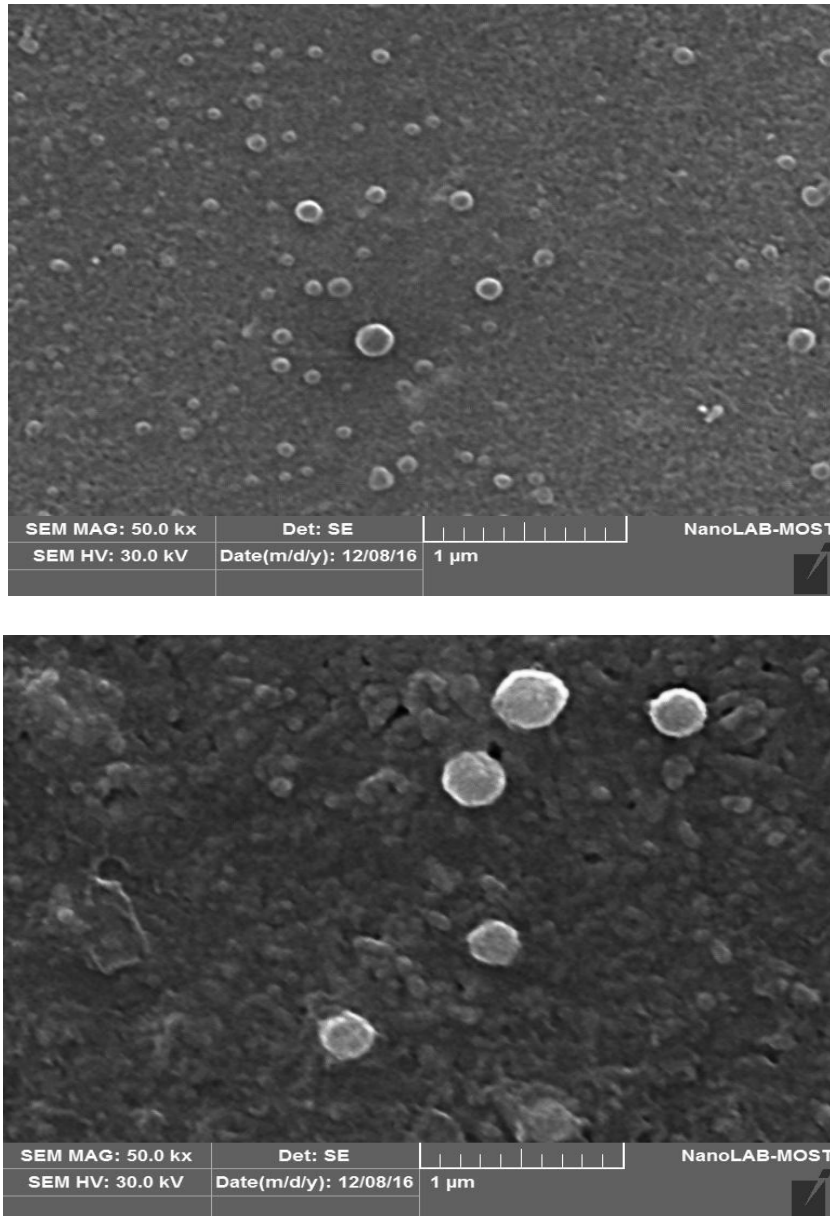
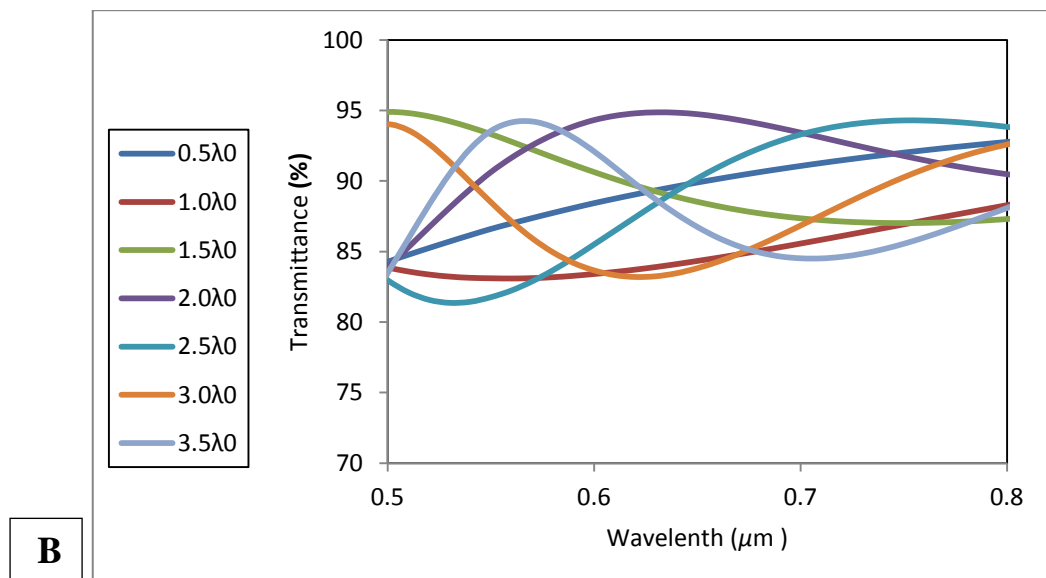
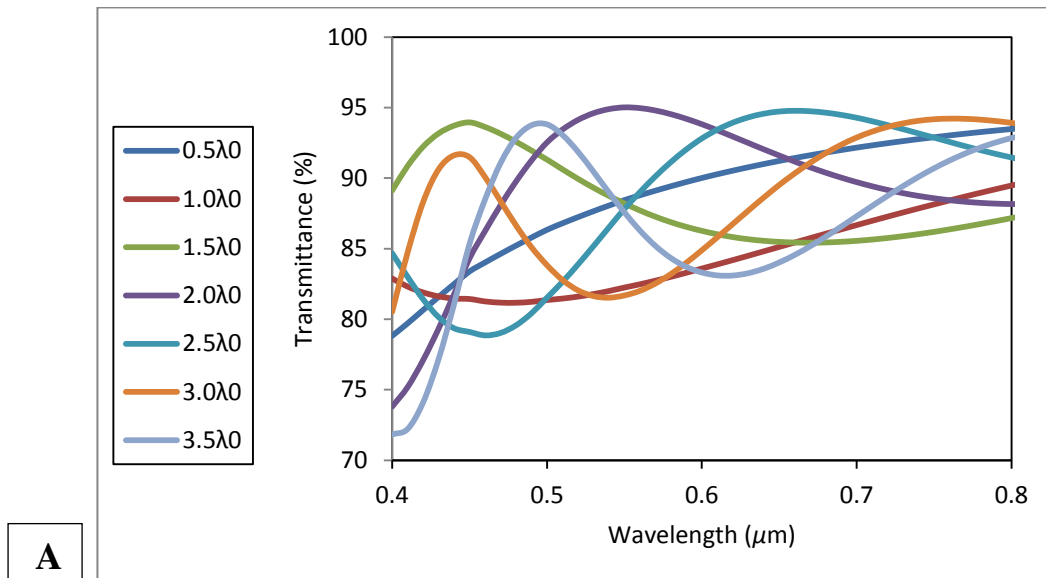


Fig. 4 SEM images of indium tin oxide a) 5% Sn concentration b)10% Sn concentration

3.2 Theoretical Computation

TFCal. ^[36] was adopted to compute transmittance versus wavelength of ITO /Glass taken into account the effect of dispersion phenomena for n and k data taken from *Refs.* ^[33-35] . Further, the effect of thickness variation also

studied at a different design wavelength : $\lambda_0=0.550 \text{ nm}$, $\lambda_0=0.6328 \text{ nm}$ and $\lambda_0=1.064 \text{ }\mu\text{m}$. Fig.(5) despite the transmission profile and Table (1) summarized the output data.



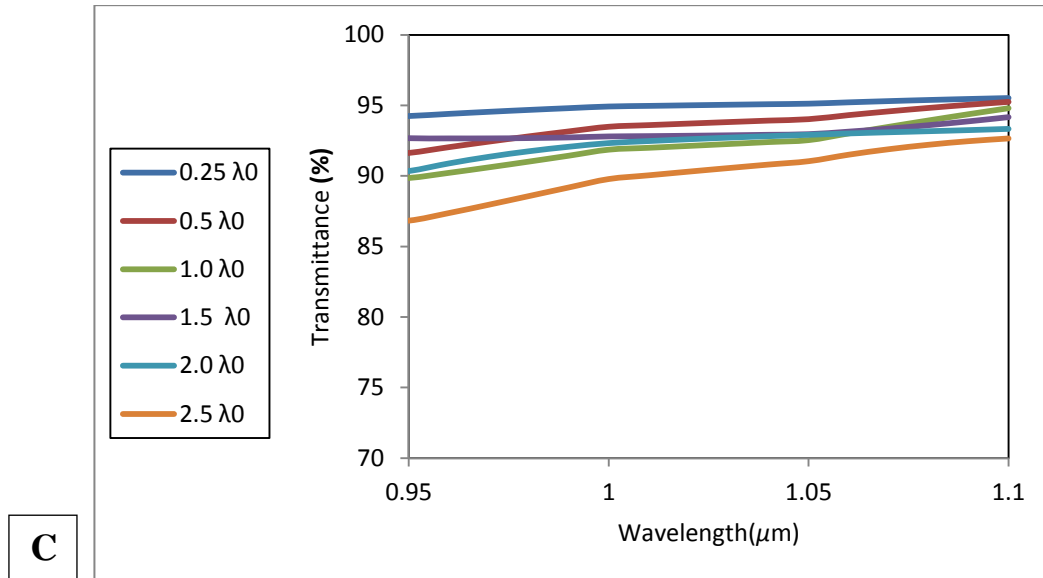


Fig.(5) Computed transmittance of ITO /Glass at different design wavelength: (A) $\lambda_0=0.550 \text{ nm}$, (B) $\lambda_0=0.6328 \text{ nm}$ and (C) $\lambda_0=1.064 \text{ }\mu\text{m}$.

Table (1) : Output geometrical thickness and transmittance data.

<i>Optical thickness</i> (λ_0)	$\lambda_0=0.55\mu \text{ m}$		$\lambda_0=0.6328\mu \text{ m}$		$\lambda_0=1.064\mu \text{ m}$	
	<i>d</i> (nm)	T(%)	<i>d</i> (nm)	T(%)	<i>d</i> (nm)	T(%)
0.25	-	-	-	-	42.7	95.2
0.5	35.1	88.4	42.2	89.3	85.4	94.3
1.0	71.4	82.2	84.4	84.0	170.8	93.0
1.5	107.1	88.2	126.6	89.2	251.2	93.2
2.0	142.8	95.0	168.8	94.8	341.6	93.0
2.5	178.6	87.8	210.9	88.4	426.9	91.0
3.0	214.3	81.6	253.2	83.2	-	-
3.5	250.0	87.6	295.4	88.7	-	-

The tabulated results are gaining importance in providing us with a clear vision and preliminary geometrical thickness range of ITO material deposited on glass as substrate. In the process, we have eliminated the traditional standard practice in the conduct of research, which requires many attempts are subject to what is known as the (*Trial and error*) concept which causes wasted evident in the use of materials, techniques and devices testing and measurements.

3.3 Experimental Results

3.3.1 Refractive index and extinction coefficient

From experimental data of thin film preparation, the optical constants; refractive index n and extinction coefficient k of ITO film of different thickness range and impurity concentration ratios (5% and 10%) as a function of wavelength (0.400-1.10 μm) were investigated and shown in Fig. (6). n and k curves show good stability in along wavelengths range (400-1100nm) which include three spectral regions, namely; ultraviolet, the visible region and near-infrared. Noting from Fig.(6) that the refractive index and attenuation coefficient k for 5% concentration decreases as the wavelengths increased within the region under study. Furthermore the n values approaching glass refractive index for wavelengths greater than 700nm.

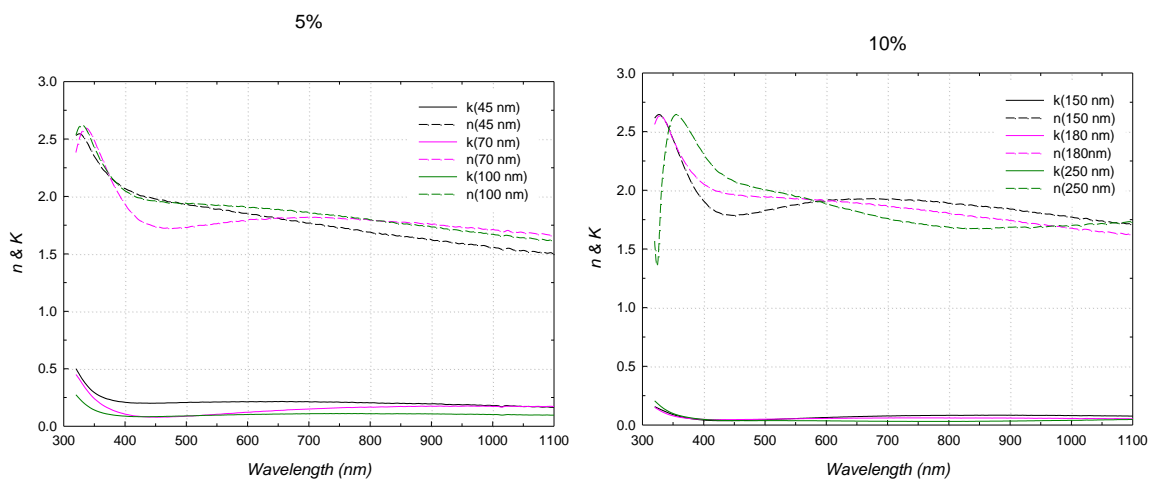


Fig. (6) The effect of ITO thickness on the refractive index and extinction coefficient of film vs. wavelength for impurity ratios 5% and 10%.

The color map of the variation in n and k values results due to thickness and wavelength variation was shown in Fig.(7).

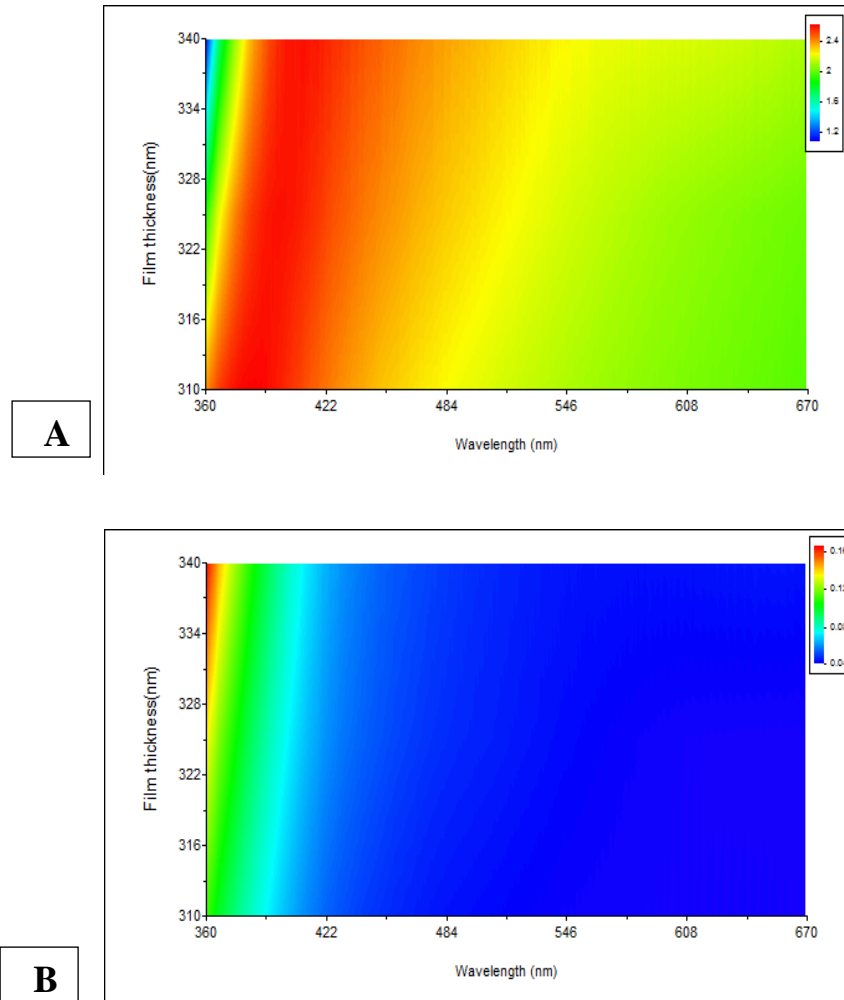


Fig.(7) Contour lines of : (A) n - and (B) k - values due to thickness and wavelength variation.

3.3.2 Effect of thickness variation on transmittance profile

The behavior of decreasing refractive index n for wavelengths greater than 700nm is an important result, because it corresponds transmission increasing of ITO /glass at near-infrared wavelength as shown in Figs.(8)and (9). For Nd-YAG laser line $1.064\mu\text{m}$,

For 5% concentration the transmission of an assembly was 91.5% in comparison with that for uncoated glass which has 84.0%. The best measuring ITO thickness suitable for anti-reflective was ultra thickness of 45nm.

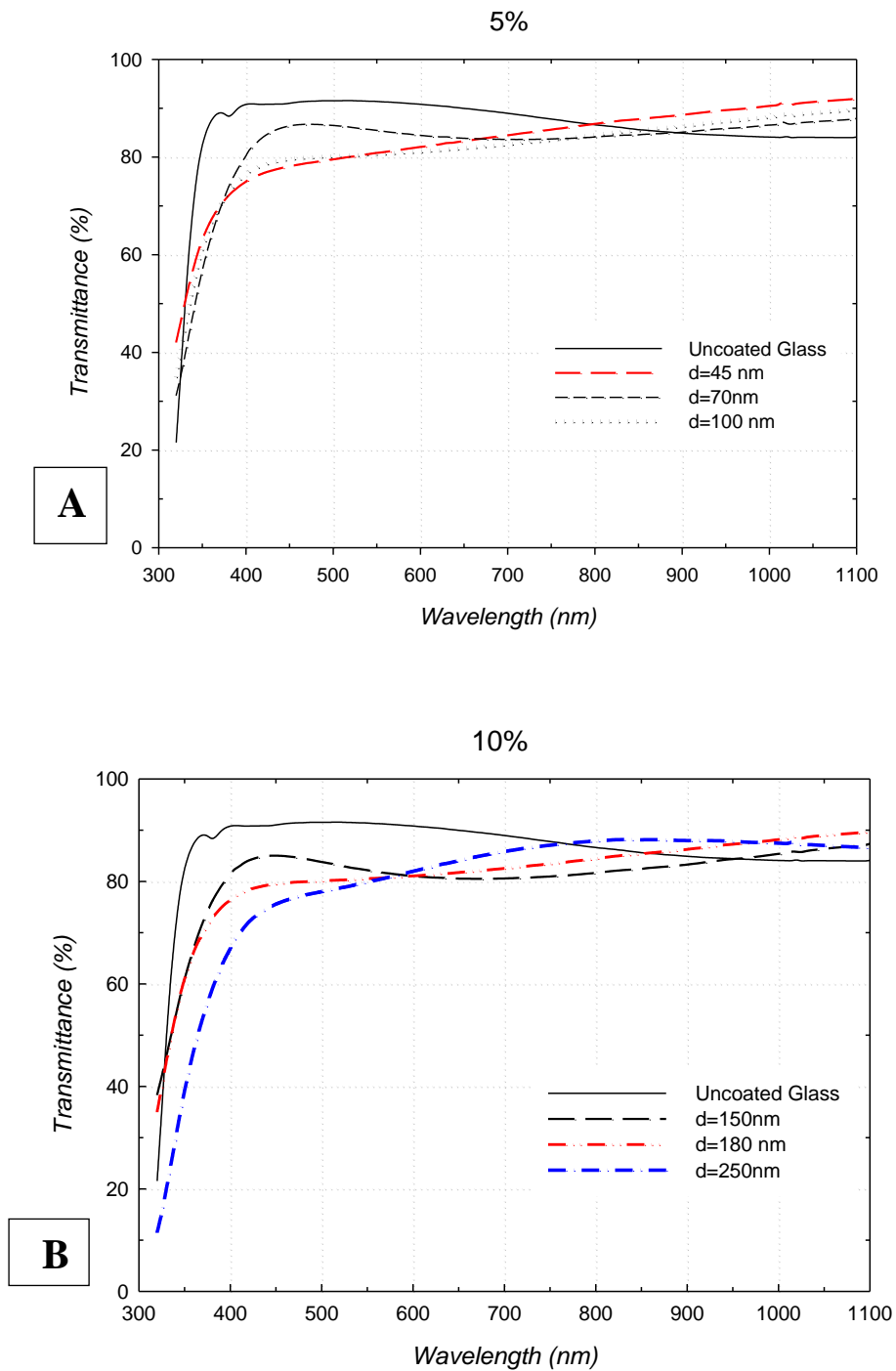


Fig.(8)Effect of ITO thickness variation on the transmission of glass vs. wavelength for different concentration (A) 5% , (B) 10%.

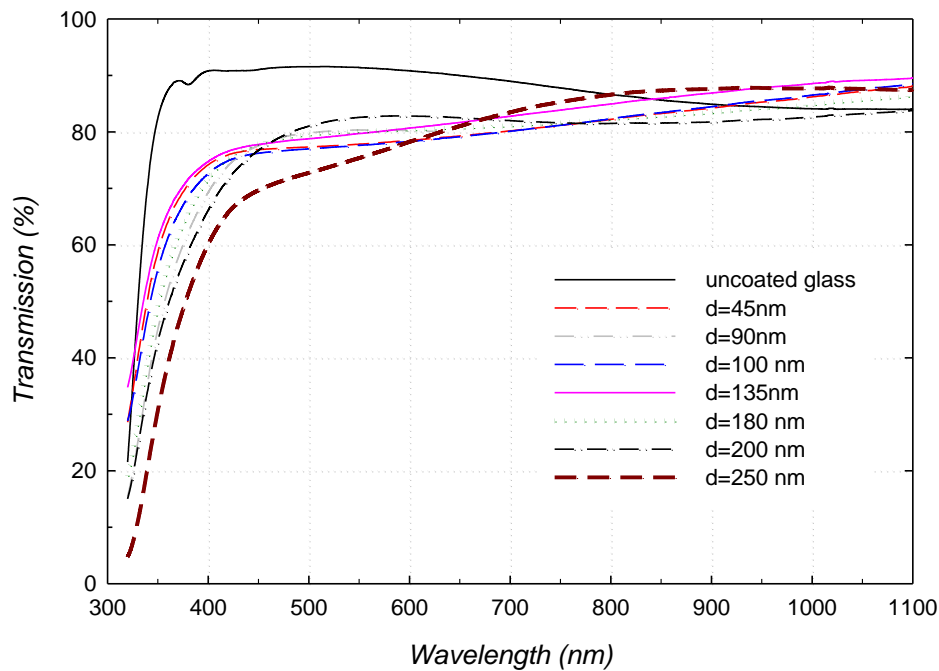
Transmission vs. Thickness

Fig.(9) Measured transmission of ITO / glass vs. wavelength of 5% concentration over thickness range (45-250 nm).

4. Conclusion

The current study has succeeded in overcoming two problems: the first , using high refractive , weakly absorbing ITO materials to obtain ultra-thin ARC's coating . This was done through the theoretical analysis of ITO/ glass transmission, which provides a clear vision and preliminary thickness range of ITO material before sample preparation. The second one the use of spray pyrolysis method for the first time to obtain ARC's of various optical constants through mixing materials with different concentrations.

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